FISCHERSCOPE® X-RAY XDV®-SDD



DPP+ digital pulse processor:

Fast and precise measurement results

RoHS Analysis: Determination of pollutants with high detection accuracy and outstanding performance **Fast:** Thanks to short measuring times, you save valuable time



The high-end all-rounder

FISCHERSCOPE® X-RAY XDV®-SDD models are among the most powerful X-ray instruments. Their silicon drift detector is extremely sensitive to fluorescence radiation of light elements. This permits very low detection limits as well as measurement applications relating to NiP, RoHS and very thin layers < $0.05 \,\mu$ m. This is why the universal XDV®-SDD instrument performs exceedingly well in research and development, laboratory and process qualification settings. Also, its ease of use makes it indispensable in production control.



NiP/Fe: P concentration and layer thickness

Passivation layers: Cr/Zn/Fe

The XDV®-SDD system is especially well suited for precise trace analysis and rapid monitoring of pollutant limit values. For example, in plastics it can be used to determine critical chemical elements such as lead, mercury and cadmium with detection limits of just a few ppm.

Features

- Universal instrument for the determination of pollutants in the smallest concentrations according to RoHs and for automated measurements of layers, including < 0.05 µm
- Stepless measuring distance with measuring top down
- Microfocus tube with tungsten anode
- 4-fold changeable apertures
- 6-fold changeable filter
- Silicon drift detector 50 mm² for highest precision on thin layers
- Aperture (collimator) up to 3 mm: Highest intensity for shortest measuring time even with difficult samples (thinnest coatings, Si wafers, conversion layers), light elements (fuel cells, Al components)
- Programmable measuring stage for automated measurements on small structures
- Fully protected instrument with type approval according to current radiation protection legislation